Graphene: Wafer scale production

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- 3. Integration
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Important milestones





We are expanding our global presence





Graphenea sites





CVD & GO Production Lab @ Miramon Technology Park (San Sebastian, Spain)

Research @ CIC nanogune (San Sebastian, Spain)



Graphene synthesis





New facilities

- New 8" CVD system
- Cleanroom class ISO7
- GO pilot plant 1Tone/year





Clean room CVD graphene

GO Pilot plant

Large team



Graphenea FTE (#)



Source: Graphenea



Graphenea GO Product Range

Graphene oxide



Form	Dispersion of graphene oxide sheets	Carbon	49-56%
Particle size	D90 29.05 - 32.9 μm	Hydrogen	0-1%
	D50 14.30 - 16.6 μm	Nitrogen	0-1%
	D10 5.90 - 6.63 µm	Sulfur	2-4%
рН	2,2-2,5	Oxygen	41-50%

SEM image

77-87%

0-1%

0-1% 0% 13-22%



Reduced graphene oxide



Form	Powder	Carbon
Electrical conductivity	≈ 667 S/m	Hydrogen
BET surface area	422.69-499.85 m ² /g	Nitrogen
Particle size (z-sizer in NMP at 0,1	260-295nm	Sulfur
mg/mL):		Oxygen
Density	1,91 g/cm ³	

SEM image



Functionalized graphene oxide

Customised functionalization:

Compatibilisation with matrix ٠







Graphenea CVD Product Range



Graphene on different substrates



Graphene on Cu







Raman shift (cm⁻¹)



G/SiO₂/Si

Graphenea CVD production capacity roadmap



Graphene is intrinsically cheap due to low marginal cost!



Source: Graphenea estimations



Graphene films





Production scale

- 3 cold walled CVD reactors
- Production of 100mm, 150mmm and 200mm graphene wafers



100mm CVD reactor



150mm CVD reactor & 200mm reactor

Research scale

Commercial scale



Monolayer Graphene Chemical Vapour Deposition (CVD)

Catalyst: Cu foil



GROWTH



- Advantages:
- Homogeneous growth
- >95% Monolayer
- Few defects
- Good properties
- Optimized transfer process



Nucleation	Coalescence	Continuous film



CVD Graphene Transfer

Graphene on catalyst

Graphene onto the desire substrate





 The quality of the transfer and the substrate supporting graphene together with the quality of the interface between graphene and the substrate have large impacts on the properties of graphene and device performance



CVD Graphene Transfer Importance of the substrate

The type of substrate will define the transfer process







- Structured substrates
- Perforated substrates: holes, cavities
- Water soluble substrates
- Number
- Size: 1x1mm² up to 4"
- Shape: rectangular, circular..
- Type of Material: CaF_2 , Si_3N_4 , Al_2O_3 ..
- Roughness
- Hydrophobicity



CVD Graphene Transfer

There is no standard process for all the substrates and applications

- Wet Transfer
- Dry Transfer
- Semi-dry Transfer

ANALYSIS

CVD Graphene characterisation

Scanning Electron Microscopy (SEM)

Transmission Electron Microscopy (TEM)



Atomic Force Microscopy







Electronic characterisation





Graphenea



X-Ray Photoelectron Spectroscopy (XPS)



ANALYSIS

CVD Graphene characterisation





- ✓ Monolayer continuous films
- \checkmark Polycrystalline: grain sizes up to 20 μm



INTEGRATION

Substrate effect on Graphene

Electronic characterisation



Substrate influence on mobility





Encapsulation



1500

1000

500 -

-6

Annealed at 225 °

 $\mu = 1500 - 2000 \text{ cr}$ n_a = 2*10¹² /cm²

Ambient air, organic solvents, chemicals, lithography resist

Lead to graphene doping and hysteretic behaviour in characteristics of FETs

Encapsulation of graphene with AI_2O_3

A.A. Asade et.al. Nanoscale 7, 3558 (2015)



-6

-2

✓ Direct deposition of Al₂O₃ by ALD

INTEGRATION

✓ AI seed layer growth by e-beam evaporation + AI_2O_3 by ALD

Oxide growth on seed layer

A.A. Asade et.al. Nanoscale 7, 3558 (2015)

Encapsulation



INTEGRATION





Direct growth of AI_2O_3 by ALD

- ✓ Hysteresis
- ✓ Not stable over time



Al seed layer + AI_2O_3 by ALD

- ✓ No hysteresis
- ✓ Stable over time

A.A. Asade et.al. Nanoscale 7, 3558 (2015)



75% of passivated transistors exhibited a conductance minimum and low hysteresis

٠

E_{gate} (V/nm)



INTEGRATION

Graphene optoelectronic mixer

THALES



- ✓ 30 GHz optoelectronic mixing
- ✓ Frequency down conversion to 100MHz

A. Montanaro et.al. Nano Lett. 16, 2988 (2016)



Graphene Integration

The application will define the graphene requirements

- Properties: Mobility, sheet resistance, transparency...
- Contamination limits: polymer residues, metal content
- Integration: Suspended, back-end, front-end..

Multilayer samples Stacking





Suspended graphene Encapsulation Image: Constraint of the second seco



APPLICATIONS

Graphene in NEMS/MEMS

Suspended graphene in pressure sensors



Development of homogeneous and high quality CVD graphene

APPLICATIONS

Graphene Interferometric Modulator Display (GIMOD)



Graphene for mechanical pixels





Bilayer CVD Graphene suspended onto 50microns cavities that compose the Flagship logo







GRAPHENE

Broadband image sensor array

Graphene-quantum dot photodetector array

- Monolithic integration of CMOS ROIC with graphene
- Graphene operates as a high mobility phototransistor
- QDs sensitising layer (PbS)
- Sensitive to UV, visible and IR light (300-2,000nm)



The Institute of Photonic Sciences

S. Goossens et.al. Nat. Photon. 11, 366 (2017)



Broadband image sensor array

Operates as digital camera

APPLICATIONS

 Graphene-QD image sensor captures reflection images from objects illuminated by a light source (office illumination)





99.8% of pixels functional

conditions

GRAP

○ >95% pixels sensitive to irradiance corresponding to partial-moon and twilight

oossens et.al. Nat. Photon. **11**, 366 (2017)



APPLICATIONS

Ultra-sensitive and low-cost Graphene Quantum-Dot Photodetector

Non-invasive health monitoring applications



- ✓ Flexible and transparent
- Blood volume
- ✓ Heart rate
- ✓ Ultra-sensitive with a gain of 10⁸ carriers per absorbed photon
- ✓ Sensitive to both visible and infrared light
- ✓ No cooling required







APPLICATIONS

GRAPHENE

Graphene flexible WiFi receiver



- 2.4 GHz receiver circuits on plastic
- Ideal for IoT and flexible electronics





Source: McKinsey



Power Sun Roof

APPLICATIONS

Graphene flexible Hall sensor



- High sensitivity, linearity and flexibility
- The key factor determining sensitivity of Hall effect sensors is high electron mobility





Source: Honeywell





Challenges

It is necessary to develop a customised material depending on the application and provide an easy integration method in order to promote graphene into commercial applications





Integration Opportunities - GFET platform

Strategy to aid graphene integration into commercial products

- Semiconductor industry not interested in few thousand wafers market – fill gap in value chain
- Commercialise GFET wafers
- Targeted markets: biosensors, sensors (photosensors), etc.



GFET platform





Graphene market is very small and driven by Researchrelated demand

Global Graphene market forecast (\$M)



Source: Graphenea estimations



Time to market – Aerospace industry



Source: ESA

C Graphenea Each application requires a specific type and grade of graphene



Illustrative TRL application map



Advanced materials that needed > 20 yrs

- ✓ Transistor
- ✓ Carbon fibre
- ✓ Fluorescent lamp
- ✓ Liquid crystals
- ✓ Kevlar
- ✓ PVC
- ✓ PE





Bell Labs 1947



Quantum dots - How things can change dramatically







Conclusions

- Customised graphene material is required for each specific application
- ✓ Many technological challenges still remain
- Many diverse multifunctional prototypes have been successfully fabricated
- We hope graphene will be a success story similar to QDs